

Supplementary Material

Enhanced photoelectrochemical response of SnSe₂ nanosheets

Zhen Fang,^{*,a} Shenghua Hao,^a Liuyang Long,^a Hui Fang,^a Tingting Qiang^a
and Yixuan Song^a

^a Key Laboratory of Functional Molecular Solids, Ministry of Education.
Center for Nano Science and Technology. College of Chemistry and
Materials Science, Anhui Normal University, Wuhu, 241000, P. R. China;
E-mail: fzfscn@mail.ahnu.edu.cn

S1. Experimental section

1.1 Preparation of stacked SnSe₂ nanosheets

All the chemicals were of analytical grade and used as received without further purification. In a typical synthesis of SnSe₂ nanosheets (SnSe₂ NSs), SnCl₂·2H₂O (0.1 mmol), SeO₂ (0.1 mmol), and poly (vinyl pyrrolidone) (PVP, 6 g) is added into benzyl alcohol (40 mL). After vigorous magnetic stirring at room temperature for 0.5 h, a deep orange-colored suspending solution was formed. Then the mixture was transferred into a 60 mL teflonlined stainless steel autoclave and heated at 180 °C for 16 h. The product was obtained by centrifuged at 8000 rpm for 5 minutes. After washed several times with absolute alcohol and acetone, the product was dried at 80 °C in air. To study the influence factors on the composition, size, and shape of the final product, the experimental parameters, such as the surfactant and the solvent, have been varied during the synthesis of SnSe₂ NSs.

1.2 Preparation of SnSe₂ nanoplates

In a typical synthesis of SnSe₂ nanoplates (SnSe₂ NSs), when the experiment was take place at 220 °C with other reaction conditions remain the same as the synthesis of SnSe₂ nanosheets, SnSe₂ nanoplates (NPs) was got.

	synthesis temperature	diameter	thickness
SnSe ₂ NSs	180 °C	~1 μm	~20 nm
SnSe ₂ NPs	220 °C	~5 μm	~200 nm

Table 1

1.3 Sample characterization

The resulting products were characterized with X-ray powder diffraction (XRD) using a Shimadzu X-ray diffractometer (XRD-6000) with Cu K α irradiation (λ =1.54187 Å). The morphology of the as-prepared samples was examined by field-emission scanning electron microscopy (FESEM, Hitachi S-4800 at an accelerating voltage of 5 kV). High-resolution transmission electron microscopy (HRTEM) images, selected area electron diffraction (SAED) were obtained from a FEI tecnai G2 transmission electron microscope working at an accelerating voltage of 200 kV. Before HRTEM observation, the sample was dispersed in alcohol through an ultrasonication process, and then a drop of the dispersion was placed on a copper grid coated with carbon film, which was dried naturally at room temperature. UV-vis-NIR diffuse reflection spectra of the supernatants were collected on a DUV-3700 UV-vis-NIR spectrophotometer at room temperature. The electronic structure of the product was characterized with X-ray photoemission spectroscopy (XPS, Kratos Axis UltraDLD, monochromatized Al K α source) operated at a base pressure of 5×10^{-10} Torr. Atomic force microscopy (AFM) measurements were conducted with a Mutilmode V AFM system (Veeco).

Liquid Chromatography-Mass Spectrometry (LC-MS MOF Agilent 6200) was used to analyze the solvent after reaction.

1.4 Potoelectrochemical measurements

The Potoelectrochemical (PEC) tests were carried out in a conventional three-electrode. A Pt mesh and Ag/AgCl were used as the counter and reference electrodes, respectively. In a typical preparation of working electrode, 0.02g SnSe₂ NSs or 0.02g SnSe₂ NPs were dissolved in 1mL absolute alcohol, then 0.3 mL of the prepared solution were deposited on the ITO substrate employed as the working electrode with an area of 2*2 cm². 0.1 M Na₂SO₄ solution was used as the electrolyte (pH=7.5). Current – voltage curves, impedance – potential measurements were recorded by an electrochemical workstation (CHI 660D, Chenhua Co., Ltd., China). A 500 W Xe lamp (CHF-XM-500, Changtuo Technology Co., Ltd.) equipped with an ultraviolet cutoff filter ($\lambda > 400$ nm) were employed to study visible light-dependent PEC response. The integrated visible light intensity was calculated. 200 mW · cm⁻² measured with a radiometer.

S2. XRD pattern obtained by drop-casting the products dispersed in anhydrous ethanol onto planar substrates

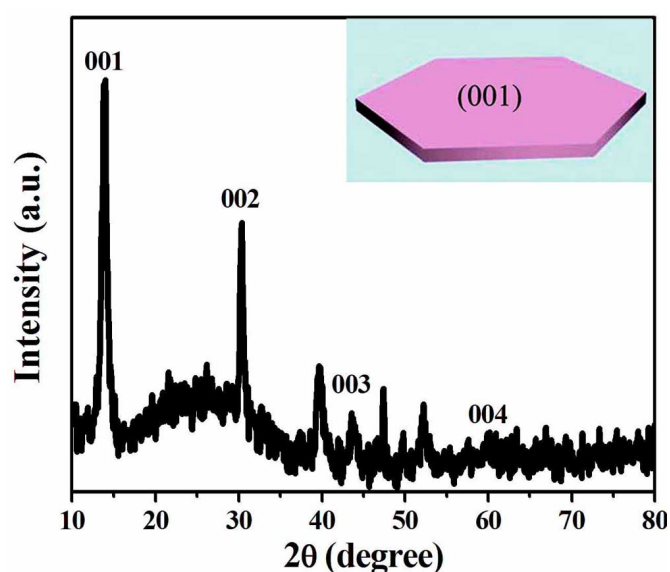


Fig. S1. (001)-oriented XRD pattern of SnSe₂ nanosheets.

S3. XPS spectra of SnSe₂ nanosheets

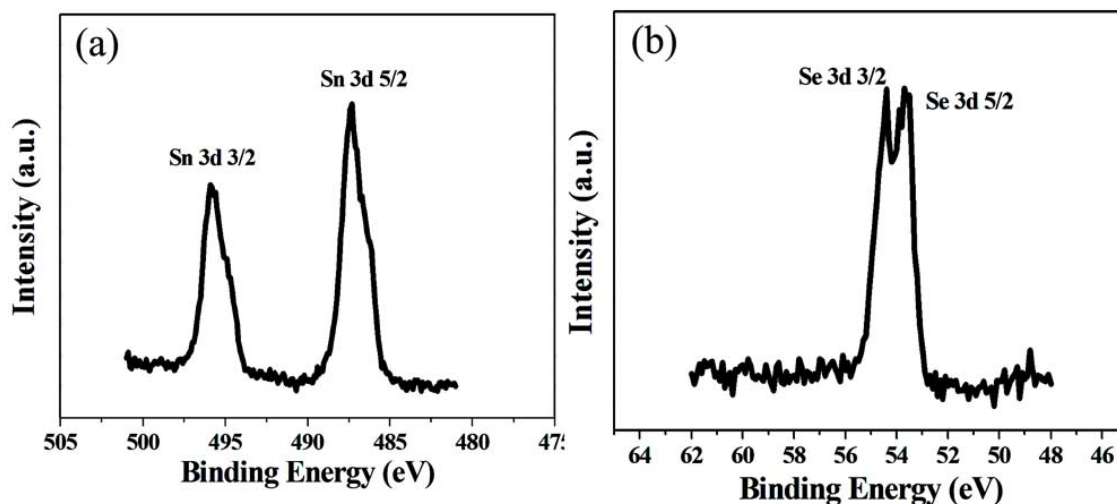


Fig. S2. X-ray photoelectron spectroscopy of the products.

S4. Crystal structure of hexagonal SnSe₂ and AFM of SnSe₂ nanosheets

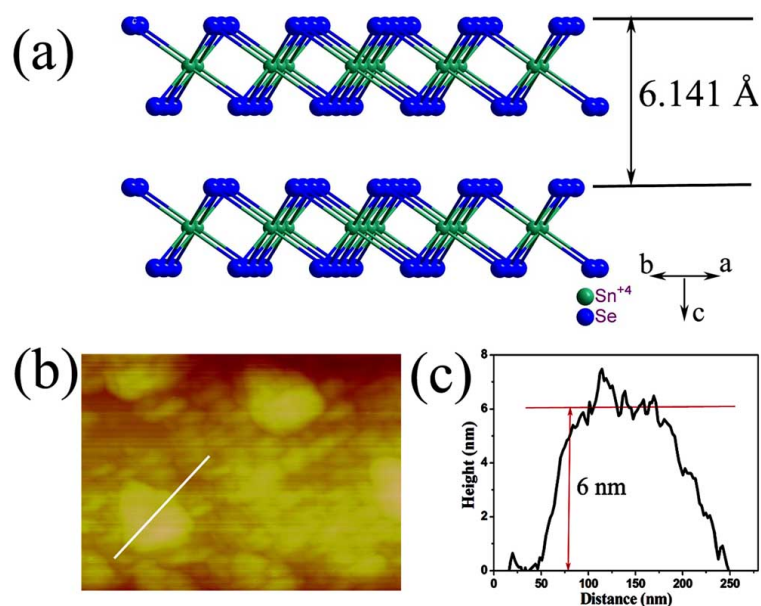


Fig. S3. (a) The schematic unit cell structure of hexagonal SnSe₂, in which the triple layer of Se-Sn-Se is separated by 6.141 Å. (b) AFM image and (c) The corresponding height profile of SnSe₂ NS.

S5. Effects of the solvent

In our experiment, benzyl alcohol reduced Se to Se²⁻. If ethanol or water

with less reducibility were used as solvent instead of benzyl alcohol, only hexagonal structural selenium was obtained (Fig. S4). The results show that benzyl alcohol is an appropriate solvent that is helpful to get the phase pure SnSe_2 .

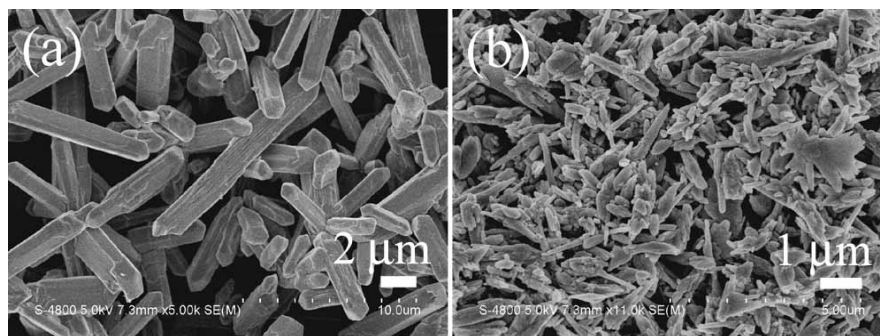


Fig. S4. SEM images of Se precursor when (a) Using ethanol as reaction solvent. (b) Using water as reaction solvent.

S6. Effect of temperature

The experimental temperature also has effect on the final product. XRD and SEM results (Fig. S5) showed that only hexagonal structural Se was obtained at low temperature (160 °C). Thicker SnSe_2 nanoplates (NPs) were got at higher temperature (220 °C). As shown in Fig. 1f, the SnSe_2 NPs are ~ 200 nm thickness and 5 μm in diameter. It indicated that 180 °C is the most appropriate temperature to synthesis SnSe_2 nanosheets.

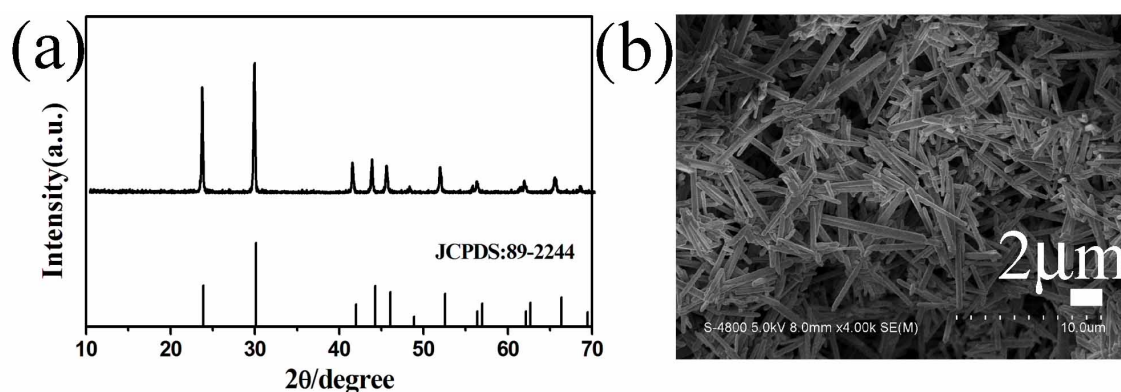


Fig. S5. (a) XRD pattern of Se obtained at 160 °C and (b) SEM image of Se obtained at 160 °C.

S7. SEM image of as-synthesized samples obtained by using 8 g PVP

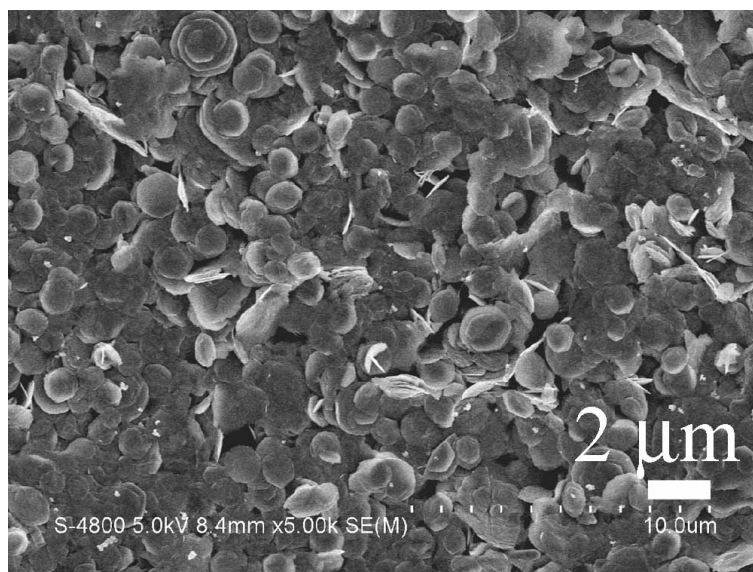


Fig. S6. SEM image of as-synthesized samples obtained by using 8g PVP

S8. Digital images of as-synthesized samples obtained by using different surfactant at the room temperature.



Fig. S7. (a) The instantaneous digital image of adding different surfactants. (b) The digital image of adding different surfactants after 3 hours at room temperature. The second beakers are the reaction reagents with no surfactant.

S9. SEM images of as-synthesized samples obtained by using different surfactant.

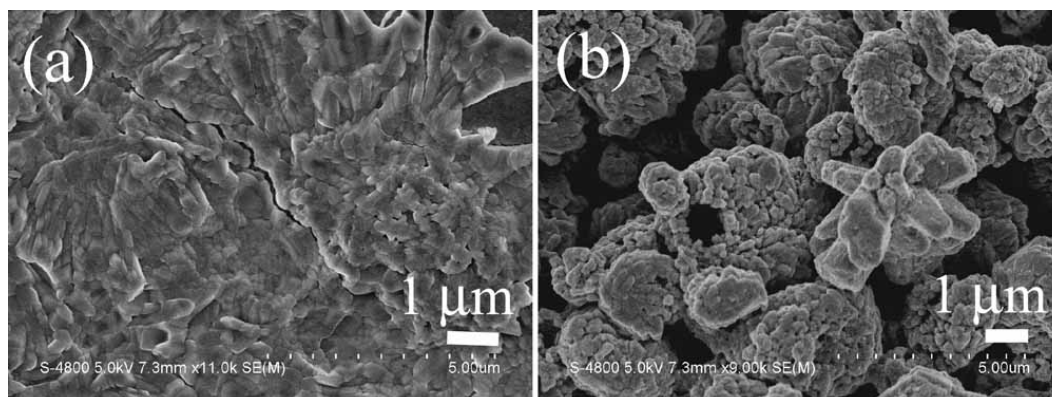


Fig. S8. (a) SEM image of using CTAB as surfactant. (b) SEM image of using PAA as surfactant.

S10. Digital image of the Sn (IV) complex solution

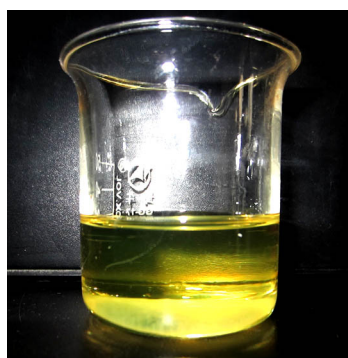


Fig. S9. Digital image of the solution obtained when $\text{SnCl}_4 \cdot 5\text{H}_2\text{O}$ and PVP was solvothermal treated in benzyl alcohol

S11. XRD of different reaction stages

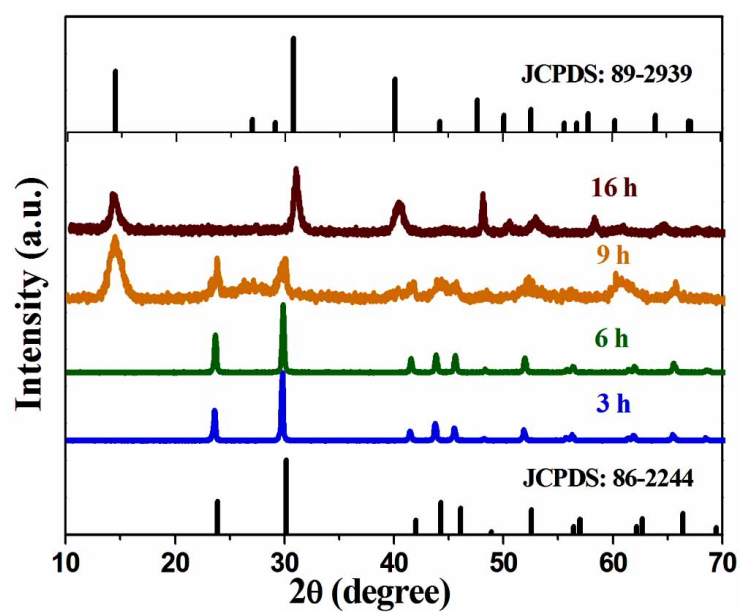


Fig. S10. XRD images of as-synthesized samples obtained by hydrothermal reaction for different time.

S12. SEM images of different reaction stages

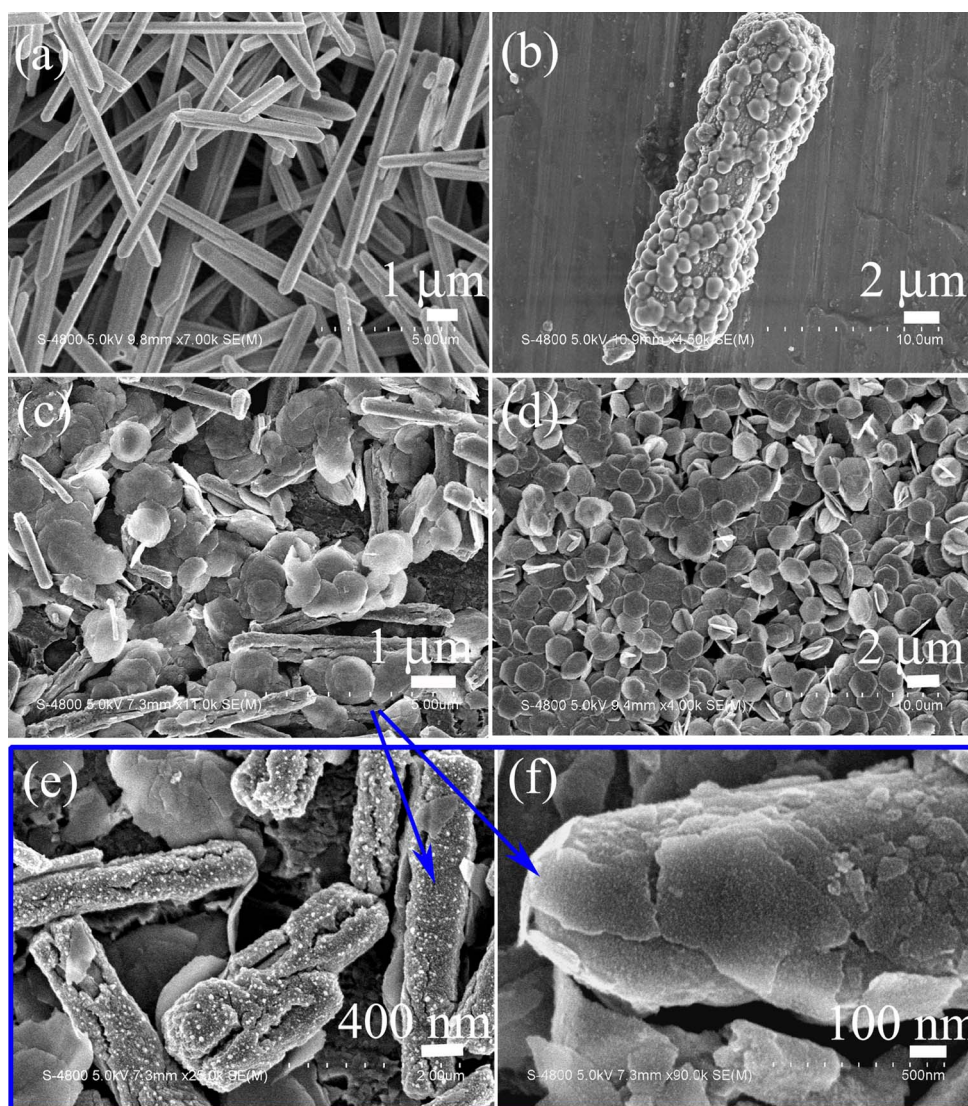


Figure S11. SEM images of aliquots taken from the different reaction stages. (a) 3 h, hexagonal structural Se. (b) 6 h, SnSe₂ nanoparticles were formed on the surface of rod-like Se. (c) 9 h, irregular SnSe₂ thinner sheets were fabricated. (d) 16 h, perfect SnSe₂ nanosheets. (e) and (f) the high magnification SEM images of (c).

S13. LC-MS of The obtained solution after reaction for 6 h

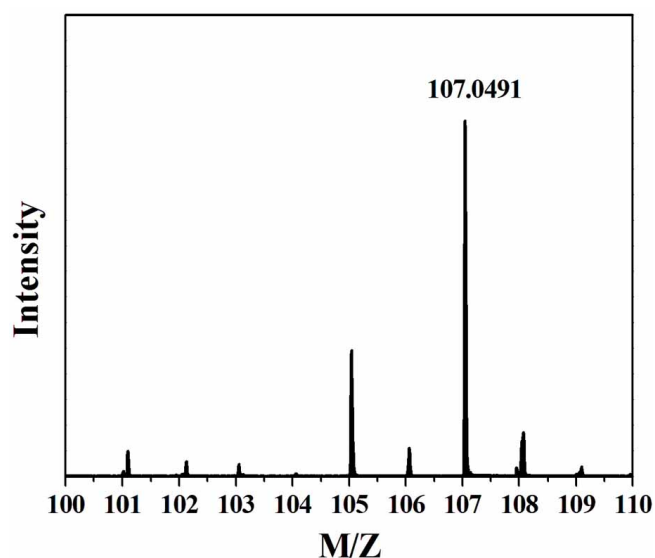


Figure S12. Mass spectra of the benzaldehyde.

S14. Indirect and direct band gaps of the SnSe₂ NSs and SnSe₂ NPs

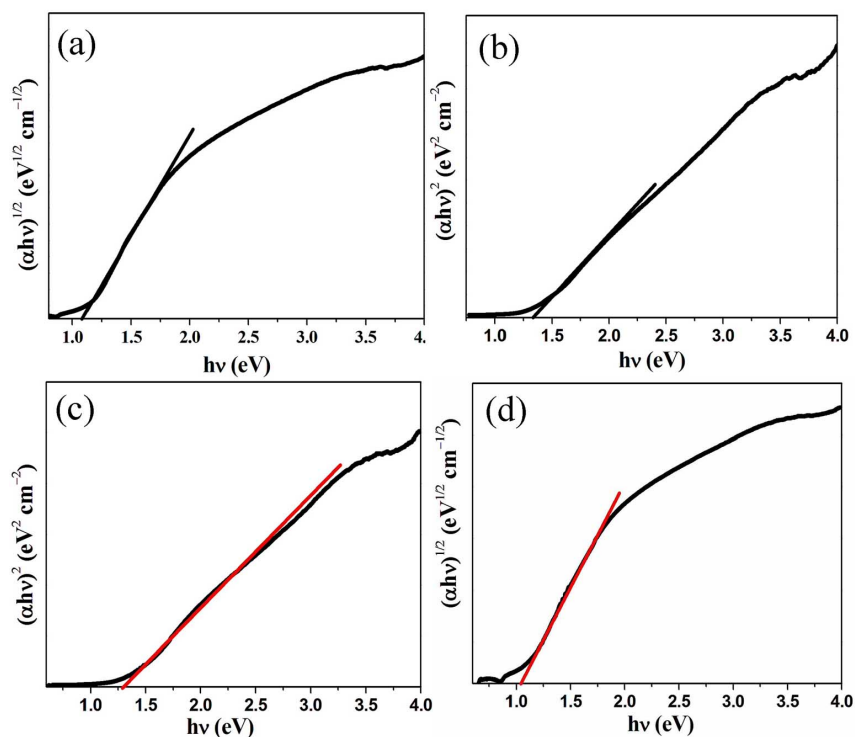


Fig. S13. (a) Direct band gap and (b) Indirect band gap of the SnSe₂ NSs.
(c) Direct band gap and (d) Indirect band gap of the SnSe₂ NPs.

S15. Characterization of the samples dropped on the ITO substrate

Fig. S14 showed the SEM images of ITO substrate with the prepared samples. Fig. S14a, b, c are the images of three segments of ITO substrate with SnSe₂ NSs, it showed that the thickness of the SnSe₂ NSs deposited on the ITO substrate was about 3-3.5 μm . Fig. S14d, e, f are the images of three segments of ITO substrate with SnSe₂ NPs, it showed that the thickness of the SnSe₂ NSs deposited on the ITO substrate was about 4-5 μm . It obvious that the stacking density of the SnSe₂ NSs samples are much bigger than SnSe₂ NPs, thus the thickness of the SnSe₂ NSs deposited on the ITO substrate was smaller than the thickness of the SnSe₂ NPs.

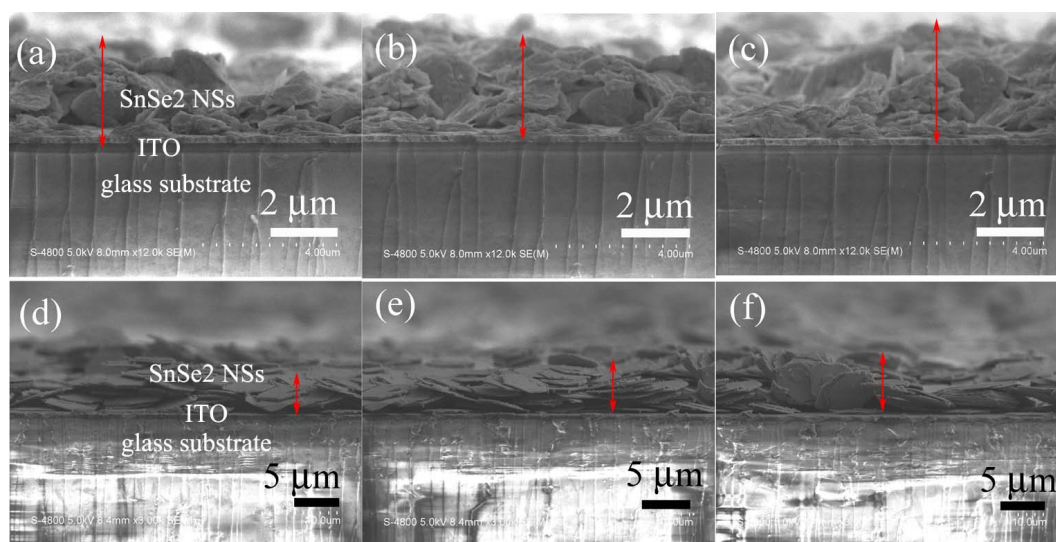


Fig. S14. (a-c) the SEM images of three segments of ITO substrate with SnSe₂ NSs. (d-f) the SEM images of three segments of ITO substrate with SnSe₂ NPs.